APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/836,464	04/18/2001	Hui Chun Liu	11258-01 US	8863

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FREEDMAN & ASSOCIATES
117 CENTREPOINTE DRIVE
SUITE 350
NEPEAN, ONTARIO,   K2G 5X3
CANADA

EXAMINER
LEE, SHUN K

ART UNIT	PAPER NUMBER
2878	

DATE MAILED: 04/16/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

<table>
<tr>
<td rowspan="2">Office Action Summary</td>
<td>Application No.
09/836,464</td>
<td>Applicant(s)
LIU, HUI CHUN</td>
<td></td>
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<tr>
<td>Examiner
Shun Lee</td>
<td>Art Unit
2878</td>
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</table>

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE <u>3</u> MONTH(S) FROM
THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed
  after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
  Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any
  earned patent term adjustment. See 37 CFR 1.704(b).

Status

1)☒ Responsive to communication(s) filed on <u>30 October 2003 and 09 February 2004</u>.

2a)☒ This action is **FINAL**.   2b)☐ This action is non-final.

3)☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is
  closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4)☒ Claim(s) <u>1-23</u> is/are pending in the application.

   4a) Of the above claim(s) _____ is/are withdrawn from consideration.

5)☐ Claim(s) _____ is/are allowed.

6)☒ Claim(s) <u>1-23</u> is/are rejected.

7)☐ Claim(s) _____ is/are objected to.

8)☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

9)☐ The specification is objected to by the Examiner.

10)☒ The drawing(s) filed on <u>09 February 2004</u> is/are: a)☒ accepted or b)☐ objected to by the Examiner.

   Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).

   Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).

11)☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

12)☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).

   a)☐ All   b)☐ Some * c)☐ None of:

     1.☐ Certified copies of the priority documents have been received.

     2.☐ Certified copies of the priority documents have been received in Application No. _____.

     3.☐ Copies of the certified copies of the priority documents have been received in this National Stage
       application from the International Bureau (PCT Rule 17.2(a)).

   * See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

1)☐ Notice of References Cited (PTO-892)

2)☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)

3)☐ Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
   Paper No(s)/Mail Date _____.

4)☐ Interview Summary (PTO-413)
   Paper No(s)/Mail Date. _____.

5)☐ Notice of Informal Patent Application (PTO-152)

6)☐ Other: _____.

DETAILED ACTION

Drawings

1.   The drawings were received on 9 February 2004. These drawings are

acceptable.

Claim Rejections - 35 USC § 102

2.   The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that

form the basis for the rejections under this section made in this Office action:

> A person shall be entitled to a patent unless –
>
> (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

3.   Claims 1-3, 8, 21, and 23 are rejected under 35 U.S.C. 102(b) as being

anticipated by Delacourt *et al.* (US 5,160,991).

In regard to claims **1-3** and **8**, Delacourt *et al.* disclose (Fig. 3) a quantum well

infrared photodetector comprising:

(a) a plurality of quantum well layers (see 2 in Fig. 1) formed of a first semiconductor

material (*e.g.*, GaAs; column 8, line 62 to column 9, line 2) and n-type doped

forming a multi-quantum well structure for providing high absorption (*i.e.*,

systematically absorbed without saturation of the detection; column 3, lines 41-45)

at temperatures other than low temperatures (*e.g.*, ambient temperature at or near

room temperature such as T = 300K; column 4, lines 40-44) and a substantial dark

current is inherent in a quantum well infrared photodetector at temperatures other

than low temperatures, wherein the plurality of doped quantum well layers (see 44

in Fig. 7) includes more than 10 quantum well layers (*e.g.*, 50 wells; column 8,

lines 62-66);

(b) barriers (see 1 and 3 in Fig. 1) between the quantum well layers (see 2 in Fig. 1)

formed of a second semiconductor material (*e.g.*, $Al_{0.15}Ga_{0.85}As$; column 8, line 62

to column 9, line 2); and

(c) contact layers (11, 13) for receiving current from the plurality of quantum well

layers (see 2 in Fig. 1).

It is noted that cryogenic cooling is defined as temperatures <150K in the

specification (pg. 4, line 15). In regard to claim **21** and claim **23** (which is dependent on

claim 21), Delacourt *et al.* disclose a method of detecting infrared radiation comprising

the steps of:

(a) detecting infrared radiation (column 1, line 48 to column 2, line 28) with a

quantum well device absent cryogenic cooling (*e.g.*, ambient temperature at or

near room temperature such as T = 300K; column 4, lines 40-44); and

(b) determining an intensity of the detected infrared radiation (column 7, lines 58-59).

Claim Rejections - 35 USC § 103

4.   The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all

obviousness rejections set forth in this Office action:

> (a) A patent may not be obtained though the invention is not identically disclosed or described as set
> forth in section 102 of this title, if the differences between the subject matter sought to be patented and
> the prior art are such that the subject matter as a whole would have been obvious at the time the
> invention was made to a person having ordinary skill in the art to which said subject matter pertains.
> Patentability shall not be negatived by the manner in which the invention was made.

5.   Claims 9-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over

Delacourt *et al.* (US 5,160,991).

In regard to claims **9-11**, Delacourt *et al.* is applied as in claims 1, 2, and 8

above. The photodetector of Delacourt *et al.* lacks an explicit description that the

contact layers comprise a third doped semiconductor. However, Delacourt *et al.* also

disclose embodiments including a contact layer (13) formed by a third doped

semiconductor (*e.g.*, 1×10^{17} - 5×10^{18} cm^{-3} n doped GaAs; column 8, line 62 to column

9, line 2) in order to obtain an ohmic contact (column 5, lines 26-28). Therefore it would

have been obvious to one having ordinary skill in the art to provide a third doped

semiconductor as the contact layers in the photodetector of Delacourt *et al.*, in order to

obtain ohmic contacts.

6.   Claims 4-6, 19, and 20 are rejected under 35 U.S.C. 103(a) as being

unpatentable over Delacourt *et al.* (US 5,160,991) in view of Liu (Semiconductor and

Semimetals, Vol. 62, pg. 129-196, 1999).

In regard to claims **4-6** which are dependent on claim 3, the photodetector of

Delacourt *et al.* lacks that the doping density Nd = $(m/\pi\hbar^2)(2k_BT)$ of the first

semiconductor material (*i.e.*, GaAs) is in the range of $1\text{-}2 \times 10^{12}$ cm^{-2}, where m is the

effective mass, $\hbar$ is the Planck constant, k_B is the Boltzmann constant, and T is the

desired operating in degrees K such as room temperature. Liu teaches (third paragraph

on pg. 168) that the doping density Nd = $(m/\pi\hbar^2)(2k_BT)$ of the first semiconductor

material (*i.e.*, GaAs) is in the range of $1\text{-}2 \times 10^{12}$ cm^{-2}, where m is the effective mass, $\hbar$

is the Planck constant, k_B is the Boltzmann constant, and T is the desired operating in

degrees K such as room temperature in order to maximize the detector limited

detectivity. Therefore it would have been obvious to one having ordinary skill in the art

to provide a doping density (*e.g.*, $Nd = (m/\pi\hbar^2)(2k_BT) =$

$(0.067 \cdot 9.1095 \times 10^{-31}$ kg/$(3.1415 \cdot 1.0546 \times 10^{-34}$ Js$))(2 \cdot 1.3806 \times 10^{-23}$ J/K$\cdot 300$K$) =$

1.4×10^{12} cm^{-2}) in the photodetector of Delacourt *et al.*, in order to maximize the

detector limited detectivity.

In regard to claims **19** and **20** which are dependent on claim 8, the photodetector

of Delacourt *et al.* lacks an explicit description that the plurality of doped quantum well

layers is designed for operation at frequencies above 1 GHz or 30 GHz. However, the

physical characteristics of GaAs/AlGaAs are well known in the art. For example, Liu

teach (pg. 176-182) that operational frequencies depend on the carrier lifetime.

Therefore it would have been obvious to one having ordinary skill in the art that the

photodetector of Delacourt *et al.* is operational at high frequencies (*e.g.*, 30 GHz).

7.   Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over

Delacourt *et al.* (US 5,160,991) in view of Liu (Semiconductor and Semimetals, Vol. 62,

pg. 129-196, 1999) as applied to claim 6 above, and further in view of Sato *et al.*

(US 5,077,593).

In regard to claim **7** which is dependent on claim 6, Delacourt *et al.* is applied as

in claims 9-11 above. The modified photodetector of Delacourt *et al.* lacks that the

n-type dopant is Si. N-type doping for GaAs is well known in the art. For example,

Sato *et al.* teach (column 5, lines 39-44) that n-type doping for GaAs comprises Ge, S,

Si, Sn, Te, or Se. Therefore it would have been obvious to one having ordinary skill in

the art that the n-type doping in the modified photodetector of Delacourt *et al.* comprise

a known n-type doping such as Si.

8.   Claim 12 is rejected under 35 U.S.C. 103(a) as being unpatentable over

Delacourt *et al.* (US 5,160,991) in view of Sato *et al.* (US 5,077,593).

In regard to claim **12** which is dependent on claim 11, Sato *et al.* is applied as

claim 7 above.

9.   Claims 13-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over

Delacourt *et al.* (US 5,160,991) in view of Sato *et al.* (US 5,077,593) as applied to claim

12 above, and further in view of Liu (Semiconductor and Semimetals, Vol. 62, pg. 129-

196, 1999).

In regard to claim **13** which is dependent on claim 12, Liu is applied as claims 4-6

above.

In regard to claims **14-15** which are dependent on claim 13, Delacourt *et al.* also

disclose that the Al fraction of the second semiconductor material (*i.e.*, $Al_{0.15}Ga_{0.85}As$;

column 8, line 62 to column 9, line 2) is 10%-50%.

In regard to claims **16** and **17** which are dependent on claim 15, Sato *et al.* is

applied as claim 7 above.

10.   Claim 18 is rejected under 35 U.S.C. 103(a) as being unpatentable over

Delacourt *et al.* (US 5,160,991) in view of Sato *et al.* (US 5,077,593) and Liu

(Semiconductor and Semimetals, Vol. 62, pg. 129-196, 1999) as applied to claim 17

above, and further in view of Wen *et al.* (US 5,352,904) and Brouns (US 5,773,831).

In regard to claim **18** which is dependent on claim 17, the modified photodetector

of Delacourt *et al.* lacks that the third doped semiconductor material is 0.1-2 µm thick.

Contact layers are well known in the art. For example, Wen *et al.* teach (column 4, lines

51-58) that the contact layer thickness should be selected to limit the electron energy

loss (e.g., 0.1 to 0.15 µm thick GaAs). As another example, Brouns teaches (column 3,

lines 27-30) that a 0.15 µm thick n-type doped GaAs contact layer is transparent to

infrared radiation. Therefore it would have been obvious to one having ordinary skill in

the art to provide 0.15 µm thick n-type doped GaAs layers as the contact layers in the

photodetector of Delacourt et al., in order to obtain infrared radiation transparent contact

layers that also minimize electron energy loss.

11.   Claim 22 is rejected under 35 U.S.C. 103(a) as being unpatentable over

Delacourt et al. (US 5,160,991) in view of Choi (US 5,384,469).

In regard to claim **22** which is dependent on claim 21, the method of

Delacourt et al. lacks that the step of determining comprises the step of filtering the dark

current component of the detected signal to determine an intensity of the detected

infrared radiation. Choi teaches (column 7, lines 8-27) filtering the dark current

component of the detected signal in order to detect the infrared radiation intensity with

more sensitivity. Therefore it would have been obvious to one having ordinary skill in

the art to filter the dark current in the method of Delacourt et al., in order to detect the

infrared radiation intensity with more sensitivity.

Response to Arguments

12.   Applicant's arguments filed 30 October 2003 have been fully considered but they

are not persuasive.

Applicant argues that the teaching of Delacourt et al. is wrong since other prior

art devices cannot operate at room temperatures. Applicant's arguments that the

teaching of Delacourt *et al.* is wrong are not persuasive since asserting without any supporting evidence that other prior art devices cannot operate at room temperatures fails to provide any explanation or evidence that the teaching of Delacourt *et al.* is wrong. Moreover even considering the argument that other prior art devices cannot operate at room temperatures, this unpersuasive argument would only at most suggest that other prior art devices did not incorporate the teachings of Delacourt *et al.* so as to operate at room temperatures.

Conclusion

13.   **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

14.   Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shun Lee whose telephone number is (571) 272-2439. The examiner can normally be reached on Monday-Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, David Porta can be reached on (571) 272-2444. The fax phone number for

the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

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you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

SL

DAVID PORTA
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800